



PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT: SIEBERT ET AL -2 EXAMINER: S.RAO
SERIAL NO: 09/716,708 GROUP: 2814
FILED: NOVEMBER 20, 2000
TITLE: EPITAXIALLY COATED SEMICONDUCTOR WAFER
AND PROCESS FOR PRODUCING IT

ATTN: BOX AFTER FINAL
Assistant Commissioner of Patents
Washington, D.C. 20231

RECEIVED
MAR 13 2003
TECHNOLOGY CENTER 2800

AMENDMENT IN RESPONSE TO FINAL OFFICE ACTION

Dear Sir:

In response to the Final Office Action dated November 6, 2002, with the time for reply having been extended for one month from FEBRUARY 6, 2003, until MARCH 6, 2003, please amend the above-identified patent application as follows:

IN THE DRAWINGS: Please substitute the enclosed formal drawings for the drawings now on file.

REMARKS

Reconsideration of this patent application is respectfully requested in view of the following remarks, and the foregoing Amendment.